

Nitrogen Trifluoride NF₃

Features

■ Purity : 99.99%

Physical state : Gas (liquefied gas)

Appearance : Compressed liquefied gas in high-pressure gas cylinder

■ Boiling point : -129 °C

■ Melting point : -208.5 °C

■ Vapor pressure: 4453 kPa (233 K)

Applications

 Specialty gas as an agent for cleaning for dry etching in semiconductor and LCD industries

Customers

■ Mitsui NF3 has been widely used among global leading semiconductor companies and LCD companies for decades